

PVD Sputtered Films Available

Al₂O₃ (Reactive & Non-Reactive)
AlCu (.5)
AlCu (1)
AlCu (4)
AlMg
AlSi (1)
AlSi (.1)
AlSi (2)
AlSi (40ppm)
AlSiCu (1/.5)
AlSiCu (1/1)
AlCuSi (2/1)
Ag
Al
AlN (Reactive)
Au
C
Co
Cr
Cr₂O₃ (Non-Reactive)
CrSi
Cr₂O₃TiO₂ (Non-Reactive)
Cr₂O₃Al₂O₃ (Non-Reactive)
Cu
CuNi (60/40)
CrMo (90/10)
Fe

FeCo (60/40)
FeCo (75/25)
Ge
GeSbTe
ITO
Mo
MoSi (2)
Nb
Ni
NiCr (80/20)
NiCr (60/40)
NiFe (19)
NiP
NiV (7)
Pd
Pt
Ru
Si
Si (Undoped)
SiC
SiCr (60/40)
Si₃N₄ (Reactive)
SiO₂ (Reactive & Non-Reactive)
Sn
Ta
Ta₂O₅ (Non-Reactive)
TaAl

TaN (Reactive)
Ti
TiN (Reactive)
TiNi
Ti₅Si₃
TiO₂ (Reactive & Non-Reactive)
W
WSi (2.7)
WTi (90/10)
WTi (80/20)
Zr
ZrO₂ (Reactive & Non-Reactive)



Evaporation Films Available

Ag Au Cr Ge Ni Pd Pt Ti

*** Contact your sales representative for further information. ***